



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 24, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

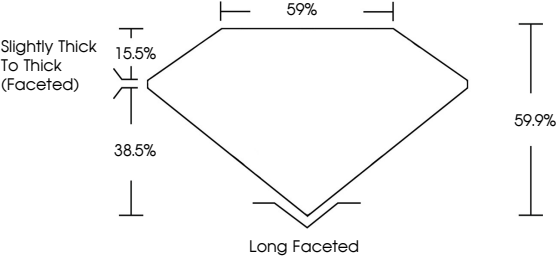
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

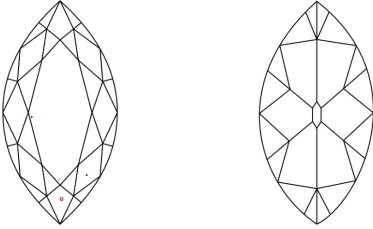
LG811646980

Report verification at [igi.org](#)

PROPORTIONS



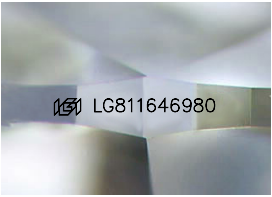
CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

Sample Image Used



COLOR

D	E	F	G	H	I	J	Faint	Very Light	Light
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CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

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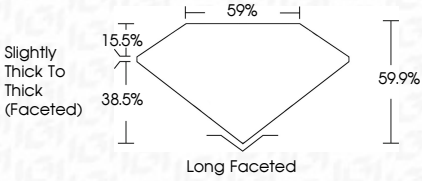
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EXCELLENT

EXCELLENT

NONE

IGI LG811646980

IGI



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MARQUISE MODIFIED BRILLIANT

1.43 CARAT

VERY LIGHT BROWN

VVS 2

59%

Slightly Thick To Thick (Faceted)

Long Faceted

EXCELLENT

EXCELLENT

NONE

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